



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

February 5, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

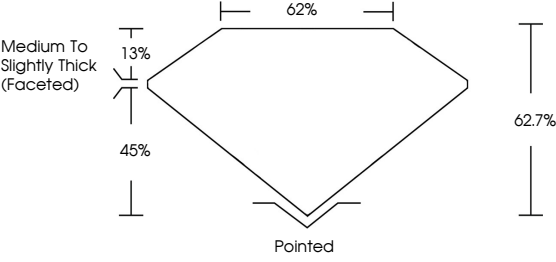
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG771637780

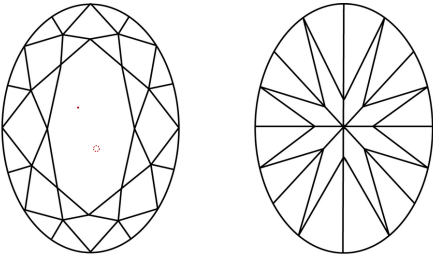
Report verification at [igi.org](#)

PROPORTIONS



Medium To Slightly Thick (Faceted)

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

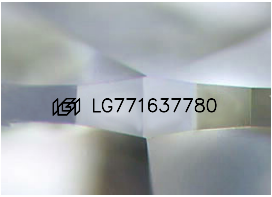
COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included



Sample Image Used



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LABORATORY GROWN DIAMOND

OVAL BRILLIANT

8.96 X 6.55 X 4.11 MM

1.52 CARAT

E

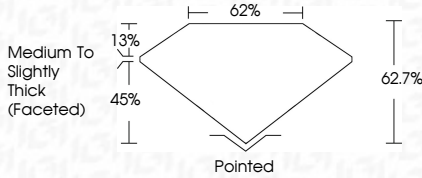
VS 1

EXCELLENT

EXCELLENT

NONE

 IGI



Medium To Slightly Thick (Faceted)

February 5, 2026

IGI Report No LG771637780

OVAL BRILLIANT

8.96 X 6.55 X 4.11 MM

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Table

Depth

Graile

Medium to Slightly Thick (Faceted)

Culet

Polish

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Inscription(s)

1.52 CARAT

E

VS 1

62.7%

62%

Pointed

EXCELLENT

EXCELLENT

NONE

 IGI



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FD - 10 20



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